

PIEZOELECTRIC RESONATOR AND THE METHOD FOR MAKING THE SAME

FIELD OF THE INVENTION

The present invention relates to a piezoelectric resonator, especially to an improved fundamental wave piezoelectric resonator in which precise measurements for frequency and constants can be measured.

BACKGROUND OF THE INVENTION

Piezoelectric resonators are widely used in electric circuits because, not only are they small and light, but also they are more stable in frequency and suffer less change over time than other electric parts. Among piezoelectric resonators, high-frequency crystal resonators, in which a cavity is formed in a part of a crystal substrate, are currently used especially for VHF and UHF bands.

Fig. 3(a) shows a plan drawing of a conventional high-frequency quartz resonator 30 and Fig. 3(b) is a cross section figure of the conventional high-frequency quartz resonator 30 at the 3(b)-3(b) plane. A cavity 32 is formed by photolithography and etching in the center of one of the main facets of an AT-cut crystal substrate 31 wherein the cavity 32 is a resonator. An electrode 33a is formed in the flat side of the crystal substrate 31, and a lead electrode 34a extends from the electrode 33a to the edge of the crystal substrate 31 and connects to a pad electrode 35a. Further an electrode 33b is formed in the cavity 32 facing against to the electrode 33a, wherein a lead electrode 34b extends from the electrode 33b to the edge of the crystal substrate and connects to a pad electrode 35b to form a high-frequency resonator 30. It has been known that the resonant frequency of a high-frequency crystal resonator 30 is inversely proportional to the thickness of the vibrate portion of the cavity 32, and the levelness and the flatness of the cavity

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32 are known to have great influences on the various characteristics of the high-frequency crystal resonator 30 and the spurious output near the resonance frequency.

When a high-frequency crystal resonator is used in a voltage-controlled crystal oscillator (VCXO), it is preferable to drive the resonator on the fundamental mode in order to widen the variable range of the frequency and not to deteriorate the capacitance ratio of the crystal resonator.

Fig. 4 shows another conventional high-frequency crystal resonator 30' that has been improved to suppress spurious appearing near the resonance frequency of the high-frequency crystal resonator shown in Fig. 3. A pair of secondary electrodes 36a and 36b are formed with a gap around a pair of main electrodes 33a and 33b. The secondary electrodes 36a and 36b are short-circuited each other, and may be grounded so that the shield effect between input and output terminals are brought about by the secondary electrode 36a and 36b.

In these high-frequency vibrators 30', it was more difficult to measure various constants accurately at higher frequencies because the various constants are measured by a method using a π circuit through the pair of electrode pads 35a, 35b connecting with the lead electrodes 34a, 34b, and the extending from the main electrodes 33a, 33b. The measurements are prone to the influence of floating capacitance and the like. For example, the IEC standards for π circuit measurements set the upper limit of the measurement to be 125 MHz, and it is not possible to precisely measure for higher frequencies beyond that upper limit.

OBJECT AND SUMMARY OF THE INVENTION

The object of the present invention is to overcome these problems and to provide a piezoelectric resonator that allows precise measurement of resonance frequencies of high-frequency crystal resonators such as 600 MHz crystal resonators.

In order to achieve this object, the present invention provides a method for making crystal resonators including an AT-cut crystal substrate, a pair of electrodes disposed roughly at the center thereof, and a pair of secondary electrodes, which
5 are formed in a shape surrounding the primary electrodes and are electrically short-circuited. The method of the present invention includes: a step for grounding the secondary electrodes and measuring a frequency of a two-terminal pair circuit, with a primary electrode and the secondary electrodes serving as output
10 terminals and another primary electrode and the secondary electrodes serving as output terminals; and a step for performing frequency adjustments when there is a difference between a measured frequency and a desired frequency.

An embodiment of the present invention provides a method
15 for making crystal resonators including an AT-cut crystal substrate including a cavity formed on one main surface thereof, a pair of primary electrodes disposed roughly at the center of the cavity, and a pair of secondary electrodes, which are formed in a shape surrounding the primary electrodes and are electrically
20 short-circuited. This method includes: a step for forming on one main surface of the AT-cut crystal substrate a cavity, first and second grooves disposed rightward and leftward from the cavity, third and fourth grooves disposed on either outer side of the first and second grooves, and fifth and sixth grooves formed above and
25 below the cavity; a step for grounding the secondary electrodes; and a step for measuring a frequency of a two terminal pair circuit and performing frequency adjustment if there is a difference between a measured frequency and a desired frequency, an input terminal for the measuring being formed by respectively
30 connecting two pad electrodes disposed at positions between the first and third grooves with one primary electrode and the secondary electrodes, and an output terminal for the measuring being formed by respectively connecting two pad electrodes

disposed at position between the second and fourth grooves with another primary electrode and the secondary electrodes.

In another embodiment of the present invention, individual crystal resonators are obtained by dividing along the first,
5 second, fifth, and sixth grooves.

The above, and other objects, features and advantages of the present invention will become apparent from the following description read in conjunction with the accompanying drawings, in which like reference numerals designate the same elements.
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BRIEF DESCRIPTION OF THE DRAWINGS

Fig. 1(a) is a front plan view drawing of high-frequency crystal resonators arranged as a matrix on an AT-cut crystal substrate according to an embodiment of the present invention;

15 Fig. 1(b) is a front plan view drawing of a high-frequency crystal resonator which is separated to an individual piece of the AT-cut crystal substrate of Fig. 1(b);

Fig. 1(c) is a back view of the high-frequency crystal resonator of Fig. 1(b);

20 Fig. 1(d) is a cross sectional view taken at the 1(d)-1(d) plane of the high-frequency crystal resonator of Fig. 1(b);

Fig. 2(a) is a front plan view drawing of high-frequency crystal resonators arranged as a matrix on an AT-cut crystal substrate according to another embodiment of the present
25 invention;

Fig. 2(b) is a front plan view drawing of a high-frequency crystal resonator which is separated to an individual piece of the AT-cut crystal substrate of Fig. 2(a);

30 Fig. 2(c) is a back view of the high-frequency crystal resonator of Fig. 2(b);

Fig. 2(d) is a cross sectional view taken at the 2(d)-2(d) plane of the high-frequency crystal resonator of Fig. 2(b);

Fig. 3(a) is a front plan view drawing of an example of a

conventional high-frequency crystal resonator;

Fig. 3(b) is a cross sectional view taken at the 3(b)-3(b) plane of the conventional high-frequency crystal resonator of Fig. 3(a);

5 Fig. 4(a) is a front plan view drawing of another example of a conventional high-frequency crystal resonator; and

Fig. 4(b) is a cross sectional view taken at the 4(b)-4(b) plane of the conventional high-frequency crystal resonator of Fig. 4(a).

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DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

The embodiments of the present invention are explained using the figures.

Fig. 1(a), 1(b), 1(c), 1(d) show the composition of a
15 high-frequency crystal resonator according to the present invention, wherein Fig. 1(a) is a plan drawing of an AT-cut crystal wafer 2, on which many high-frequency crystal resonators 1 are formed in a matrix-like arrangement. Fig. 1(b) is a plan drawing (front view) of a single high-frequency crystal resonator 1 β which
20 is cut out from the crystal wafer 2 individually and Fig. 1(c) is a back view of the high-frequency crystal resonator 1 β of Fig. 1(b). Fig. 1(d) is a cross section of the high-frequency crystal resonator 1 β taken at the 1(d)-1(d) plane.

The high-frequency crystal resonators 1 of the present
25 invention are formed on the crystal wafer 2 in a matrix-like arrangement. Here, however, a unit of a high-frequency crystal resonator 1 is explained for the sake of simplicity. At first, a cavity 3 with a predetermined thickness is formed by
photolithography and etching at roughly the center of one surface
30 of the AT-cut crystal wafer 2. Also, first and second grooves 4a and 4b are formed on the crystal wafer 2 at predetermined distances from the left and right of the cavity 3. Third and fourth grooves 4c and 4d are formed at predetermined distances

outward from the first and second grooves 4a and 4b. Furthermore, fifth and sixth grooves 4e and 4f are formed perpendicular to the first groove 4a and the second groove 4b to form a crystal substrate 2' to be used for the single high-frequency crystal resonator 1 β .

5 The crystal substrate 2' is comprised of parts α , β , γ as shown in Fig. 1(a) and are also referred to as crystal substrates 2' α , 2' β , 2' γ . The parts α , β , γ are divided by the grooves 4a, 4b, 4c, 4d, 4e and 4f formed by etching for breaking off the crystal substrates. The cavity 3 is formed by etching at the rear center
10 of β (called crystal substrate 2' β).

An electrode 5a is attached to the flat side of a crystal substrate 2' made as described above, and another electrode 5b is attached to the cavity 3, at the opposite side of the crystal substrate 2' as electrode 5a. Lead electrodes 6a and 6b extend
15 from the electrode 5a and 5b to the edges of the crystal substrate 2' β . Furthermore, the lead electrode 6a extends to the edge of the crystal substrate 2' γ and connects to a pad electrode 7 for measurement. The lead electrode 6b in the reverse side extends to the terminal electrode 6b' located at the edge of the substrate
20 2' β , and the terminal electrode 6b' is connected to a terminal electrodes 6b'' by way of the metal plating of a through hole h1. In addition, the terminal electrode 6b'' is connected to a pad electrode 8 for measurement which is formed at the edge of the crystal substrate 2' α .

25 A pair of secondary electrodes 9a and 9b are formed surrounding the driving electrodes 5a, 5b with a gap between each driving electrode 5a, 5b and lead electrodes 10a and 10b extend from the left and right edge of the secondary electrode 9a to the edge of the crystal substrate 2' β . The lead electrodes 10a and
30 10b extend over the crystal substrates 2' α and 2' γ and connect to the pad electrodes 10a' and 10b' for measurement. Furthermore, the lead electrodes 10c and 10d extend from the secondary electrodes 9a and 9b toward the edge of the crystal substrate 2' β

and connect to the terminal electrodes 10c' and 10d' which are formed at the edge of the crystal substrate 2' β . A through hole h2 is formed between the terminal electrodes 10c' and 10d', and the terminal electrodes 10c' and 10d' are electrically connected through the metal plating on the through hole h2.

By forming multiple high-frequency crystal resonators 1, each of which serve as the smallest unit, on the large wafer 2 as shown in Fig. 1(a) and by grounding the terminal 10c', the constants of the crystal resonators 1, each of which serve as the smallest unit, can be measured using the S-parameter method, which is suited for high-frequency measurements. In this case, the pad electrodes 8, 10a' serve as input terminals and the pad electrodes 7, 10b' serve as output terminals. The resulting measurements provide improved accuracy. At the same time, the pad electrodes 8, 10a', 7 and 10b' touched by a probe for measurements are positioned away from each individual resonator 2' β where the resonator is formed, and the pad electrodes 8, 10a', 7 and 10b' are separated from the individual resonator 2' β by the grooves 4a and 4b. Thus, the stress caused by the touch of the probe is moderated, the effect on the resonator 1 β is lowered, and the frequency change due to the stress-strain on measurement can be kept very small. The reason why the input pad electrodes 8, 10a' and the output pad electrodes 7, 10b' are placed diagonally to each other is to accommodate the S-parameter probe.

After the measurement of various constants and the adjustment of frequency, if needed, single high-frequency resonators 1 β are obtained by separating the grooves 4a, 4b, 4c, 4d on the edges of the crystal substrates 2' α , 2' γ and the grooves 4e and 4f on the edge of the crystal substrate 2' β . The high-frequency crystal resonator 1 β is completed by being placed at the bottom of a cavity in a ceramic package, connecting the terminal electrode 10c' of the secondary electrode 9a to the ground terminal, and closing the ceramic package with an airtight

metal lid.

Since the secondary electrodes 9a and 9b in the high-frequency crystal resonator 1 β in the present embodiment are grounded and the electric potential of the secondary electrodes 9a and 9b is the same as the ground electrode of the package, a resonator 1 β with minimum floating capacitance can be obtained. When a VCXO is made by using a high-frequency crystal resonator 1 β constructed as above, such as a 600 MHz resonator, the variable range of frequency is widened and frequency stability is improved.

Fig. 2(a), 2(b), 2(c) show another embodiment of a high-frequency crystal resonator 11. Fig. 2(a) is a plan drawing of an AT-cut crystal wafer 12, on which many high-frequency crystal resonators 11 are formed in a matrix like arrangement by photolithography and etching. Fig. 2(b) is a plan drawing (front view) of the high-frequency resonator 11 which is cut out from the crystal wafer 12 individually. Fig. 2(c) is a back view of the high-frequency resonator 11 of Fig. 2(b). Fig. 2(d) is a cross section of the high-frequency resonator 11 taken at the 2(d)-2(d) plane. Many of the cavities 3 and grooves 4 for cutting which surround the cavity 3 are formed in a matrix-like arrangement by using a photolithography and etching technique on the AT-cut crystal wafer 12 of a predetermined thickness. One high-frequency crystal resonator 11 on the AT-cut wafer 12 is described for the sake of simplicity. At the back of an individual piece of a crystal substrate 12', a cavity 3 is formed in the center, and the grooves 4 for breaking the AT-cut wafer 12 into individual pieces 12' surround the cavity 3. In the center of the flat side of the crystal substrate 12', a driving electrode 15a is formed and a leading electrode 16a extends from the electrode 15a toward the edge of the crystal substrate 12' and connects to a pad electrode 16a'. An electrode 15b is formed in the cavity 3 facing against to the electrode 15a, and a lead electrode 16b extends from the electrode 15b toward the edge of the crystal substrate

12' and connects to a pad electrode 16b' which is formed at the edge of the backside of the crystal substrate 12'. In front side, a pad electrode 16b'' is formed facing to the terminal electrode 16b'. The two electrodes 16b' and 16b'' are electrically
5 connected through a through hole h1.

Further, a pair of secondary electrodes 17a and 17b, which surround the main electrodes 15a and 15b, are formed both side of the resonator 11 facing each other. Lead electrodes 18a and 18b are extend from each secondary electrode 17a and 17b toward
10 the edge of the crystal substrate 12' and connect to the terminal electrodes 18a' and 18b' which are formed at the edge of the crystal substrate 12'. A through hole h2 is formed between the lead electrodes 18a' and 18b', which are connected electronically through the metal plating on the through hole h2. A pad electrode
15 19 is formed in the middle of the electrode 18a on the front side wherein an angle θ between the line connecting the pad electrodes 16b'' and 19 and the x axis is set to be about 60° , and the angle θ between the line connecting the pad electrodes 16a' and 19 and x axis is also set to be about 60° . Also, the above mentioned
20 angle θ may be set to be 120° . The angle is determined so that the stress-frequency sensitivity is minimized in order to lessen the frequency change due to the stress caused by touching the pad electrodes 16a', 16b'' and 19 with a probe for measurement of various constants of the high-frequency crystal resonator. It
25 is also possible to minimize the frequency change from support stress by having the high-frequency crystal resonator 11 supported at the pad electrodes 16b'' and 16a' when placing the high-frequency crystal resonator 11 in the ceramic package.

The deterioration of the capacitance ratio due to the
30 floating capacitance can be prevented by grounding the secondary electrodes 9a, 9b, 17a, 17b, and at the same time the spurious output can be effectively suppressed.

The present invention provides an accurate measurement of

various constants of the high-frequency crystal resonator. An embodiment of the present invention provides a crystal resonator which is suitable for high frequency voltage controlled crystal oscillators because the floating capacitance can be kept low and
5 the capacitance ratio can be kept small. An embodiment of the present invention provides a crystal resonator with high frequency stability in which the support influence is minimized and deterioration of the capacitance ratio is prevented.

Having described preferred embodiments of the invention
10 with reference to the accompanying drawings, it is to be understood that the invention is not limited to those precise embodiments, and that various changes and modifications may be effected therein by one skilled in the art without departing from the scope or spirit of the invention as defined in the appended
15 claims.